



Attorney's Docket No.: 42P17540

Patent

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In Re Application of: )

Swaminathan Sivakumar et al. )

U.S. Serial No: 10/750,200 )

Filed: December 30, 2003 )

For: PHOTORESIST PROCESS )  
TO ENABLE SLOPED PASSIVATION )  
BONDPAD OPENINGS FOR EASE OF )  
METAL STEP COVERINGS )

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Examiner: Chen, Eric Brice

Art Unit: 1765

**AMENDMENT AND RESPONSE**

Dear Sir:

This is in response to the Office Action mailed August 23, 2005. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

**FIRST CLASS CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to MAIL STOP \_\_\_\_\_

COMMISSIONER FOR PATENTS, P.O. Box 1450, Alexandria, VA 22313-1450

U.S. Patent and Trademark Office, Washington, D.C. 20231 on November 30, 2005

Date of Deposit

Teresa Mattox

Name of Person Mailing Correspondence

Teresa Mattox

Signature

November 30, 2005

Date

12/06/2005 HDESTA1 00000053 10750200

01 FC:1251

120.00 OP

Serial No.: 10/750,200

Attorney Docket: 42P17540